



Docket No.: M4065.0982/P982
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Chris S. Hong

Allowed: September 21, 2006

Application No.: 10/714,670

Confirmation No.: 2308

Filed: November 18, 2003

Art Unit: 2818

For: METHOD OF FORMATION OF DUAL
GATE STRUCTURE FOR IMAGERS
(AS AMENDED)

Examiner: T. T. Nguyen

**COMMENTS ON STATEMENT OF REASONS
FOR ALLOWANCE UNDER 37 C.F.R. § 1.104(E)**

MS Issue Fee
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Applicant has received the Examiner's Statement of Reasons for Allowance with the September 21, 2006 Notice of Allowance and Allowability regarding the above-identified application. Entry of the Statement into the record should not be construed as any agreement with or acquiescence in the reasoning stated by the Examiner. Each of the claims stands on its own merits and is patentable because of the combination it recites and not because of the presence or absence of any one particular element.

The Examiner's Statement was not prepared by Applicant and only contains the Examiner's possible positions in one or more reasons for allowability. Thus, any

interpretation with respect to the Examiner's Statement of Reasons for Allowance should not be imputed to the Applicant.

Dated: November 2, 2006

Respectfully submitted,

By 

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